## SUPPORTING INFORMATION

Bulk passivation and suppressing nonradiative recombination loss in 3D all-inorganic CsPbIBr<sub>2</sub> perovskite solar cell via 2D layered perovskite framework

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Fig. S1. Histogram analyses of the grain size distribution of the (a) X=0, (b) X=0.02, (c) X=0.04,(d) X=0.08 perovskite thin films deposited on bare glass substrates.



Fig. S2. Top-surface AFM image of (a) pristine CsPbIBr<sub>2</sub> and (b) PEAI doped CsPbIBr<sub>2</sub> thin film.



**Fig. S3.** Elemental mapping with the map sum spectrum (bottom right one) of the synthesized ((PEA)<sub>2</sub>PbI<sub>4</sub>)<sub>0.02</sub>(CsPbIBr<sub>2</sub>)<sub>0.98</sub> perovskite thin film on a bare glass substrate.



Fig. S4. High-resolution XPS spectrum corresponding to the analyses of C1s peak.



**Fig. S5.** Urbach energy analysis from the light absorbance spectrum of the fabricated  $((PEA)_2PbI_4)_X(CsPbIBr_2)_{1-X}$  perovskite thin films deposited on bare glass substrates.



**Fig. S6.** PL degradation test of the fabricated (a) X=0.02, and (b) X=0 based perovskite thin films under the ambient environment (RT $\approx$  27°C, RH $\approx$  84%) for initial 30 minutes.



**Fig. S7.** Light-illuminated *J-V* analyses of the fabricated PSCs using the  $((PEA)_2PbI_4)_X(CsPbIBr_2)_{1-X}$  perovskite absorber layer where X=0, 0.01, 0.02, 0.04, 1.



Fig. S8. Device repeatability concerning to the (a) *J*<sub>SC</sub>, and (b) *FF*.



Fig. S9. Device repeatability concerning to the  $V_{OC}$ .



Fig. S10. Semi-log dark J-V plot of the fabricated pristine, and champion devices.



Fig. S11. Bandgap calculation from the EQE plot of the fabricated pristine, and champion devices.



**Fig. S12.** (a) XRD pattern of the fabricated perovskite thin films (X=0, 0.02) stored under an ambient environment (RH $\approx$ 60 %, RT 26°C) for 7 days, and real-time digital photographs of the fabricated perovskite thin films having (b) X=0.02, & (c) X=0.

Perovskite thin films with 2D ratio	Position of the crystallite plane (degree)	FWHM (degree)	Crystallite size (nm)	Inter planer distance (nm)	Lattice parameter (nm)
X=0	30.60	0.1833	44.931	0.2919	0.5838
X=0.02	30.62	0.1826	53.599	0.2917	0.5834
X=0.04	30.63	0.1837	44.838	0.2916	0.5832
X=0.08	30.37	0.2086	39.460	0.2940	0.5880

**Table S1**. Calculated crystal structure parameters of the (200) crystal plane from the XRD pattern of the fabricated perovskite thin films.

**Table S2.** Statistical analyses of 40 grains of the fabricated  $((PEA)_2PbI_4)_X(CsPbIBr_2)_{1-X}$  perovskite thin films spin-coated on bare glass substrates.

Samples	Average grain size with standard deviation
X=0	350.43±0.09
	<b>709</b> nm
X=0.02	853.38±0.18
	<b>1367</b> nm
X=0.04	795.78±0.23
	<b>1109</b> nm
X=0.08	114.28±0.56
	<b>181.64</b> nm

• The bolded grain sizes are the maximum of the 30 grains of the fabricated perovskite thin films

**Table S3.** Elemental compositional ratio of the fabricated  $((PEA)_2PbI_4)_{0.02}(CsPbIBr_2)_{0.98}$  perovskite thin films from the EDX analyses.

Atomic percentage (%)
20.91
16.68
19.04
35.06
2.40
5.91

Elements	FWHM for X=0 (eV)	<b>FWHM for X=0.02 (eV)</b>
Cs 3d	2.57	1.67
Pb 4f	2.45	2.39
I 3d	2.53	1.64
Br 3d	2.74	1.74
C 1s	2.67	1.6

Table S4. XPS FWHM of the elements present in the fabricated perovskite thin films

**Table S5**. Calculated Urbach energy from the fabricated perovskite thin films using the light
 energy absorption data.

Sample	E <sub>U</sub> (m eV)
X=0	48.78
X=0.01	48.54
X=0.02	45.43
X=0.04	45.76
X=0.08	117.64
X=0.1	147.0

Device	<i>PCE</i> (F)	<i>PCE</i> ( <b>R</b> )	HI (%)
W/o	7.09	8.08	12.25
W(X=0.01)	9.35	10.09	7.33
W(X=0.02)	9.58	10.13	5.42
W(X=0.04)	7.93	8.90	10.89
W(X=1)	1.33	1.97	32.48

**Table S6.** Hysteresis index calculation from the J-V plot of the fabricated PSCs.

**Table S7.**  $J_{SC}$  values extracted from J-V, and EQE plot of the fabricated pristine and champion devices.

Device	$J_{SCJV}$ (mA/cm <sup>2</sup> )	$J_{SC EQE}$ (mA/cm <sup>2</sup> )
X=0	13.12	12.70
X=0.02	14.36	14.07

Device	$\frac{J_{SC}}{(\mathbf{mA/cm}^2)}$	<i>Voc</i> (V)	FF (%)	PCE (%)
With additive	13.53±0.70	$1.12\pm0.01$	$0.60\pm0.01$	9.23±0.69
				10.13
Without	$12.40{\pm}1.08$	$1.04 \pm 0.04$	$0.55 \pm 0.01$	7.19±0.95
additive				8.08

**Table S8.** Statistical analyses of the photovoltaic parameters of the fabricated pristine, and champion devices.

• The bolded digits correspond to the maximum achieved device *PCE* values. The whole analyses were done considering the reverse scanning J-V plot only.

**Table S9.** Electrochemical impedance spectroscopy (EIS) fitted data using an equivalent circuit model.

Device	Rs (Ω)	Rct (Ω)	Rrec (Ω)	CPEtr (S-sec <sup>-n</sup> )	CPErec (S-sec <sup>-n</sup> )
X=0	30.7	607	627.1	6.9X10 <sup>-7</sup>	1.4X10 <sup>-4</sup>
X=0.02	22.34	924.4	808.1	5.2X10 <sup>-7</sup>	1.3X10 <sup>-4</sup>

Parameters	FTO <sup>1</sup>	CsPbIBr <sub>2</sub> <sup>2</sup>	TiO <sub>2</sub> <sup>3</sup>	Spiro-
				OMeTAD <sup>4</sup>
d (nm)	200	598	505	115
	(experimental)	(experimental)	(experimental)	(experimental)
$E_g(eV)$	3.5	2.06 (experimental)	3.2	2.9
χ (eV)	4.0	3.7	4.2	2.2
Er	9	8	9	3
$N_c(cm^{-3})$	$2.2X10^{18}$	$2.0X10^{18}$	$10^{18}$	$2.5 X 10^{18}$
$N_v(cm^{-3})$	$1.8 X 10^{19}$	$5.0X10^{18}$	10 <sup>19</sup>	$1.8 X 10^{19}$
$\mu_n(cm^2/Vs)$	2.0	20	5X10 <sup>-2</sup>	2.0X10 <sup>-4</sup>
$\mu_p(cm^2/Vs)$	1.0	20	5X10 <sup>-2</sup>	2.0X10 <sup>-4</sup>
V <sub>e</sub> (cm/s)	$1.0 X 10^{7}$	$1.0 X 10^{7}$	107	$1.0X10^{7}$
$V_h(cm/s)$	$1.0 X 10^{7}$	$1.0 X 10^{7}$	107	$1.0X10^{7}$
$N_A(cm^{-3})$	0	$1.0X10^{15}$	0	$1.0X10^{22}$
$N_D(cm^{-3})$	$1.0X10^{19}$	0	$10^{18}$	0
$N_t(cm^{-3})$	$1.0 X 10^{14}$	5.12X10 <sup>15</sup>	$10^{14}$	$1.0 X 10^{14}$
		(experimental)		
$A_{\alpha}(cm^{-1})$	G 1	10X10 <sup>7</sup>	Scaps value	0 1
	Scaps value	(experimental)		Scaps value

**Table S10.** Parameters of the different layers of the PSCs for the numerical simulation usingSCAPS 1D software.

• The  $N_t$  for the champion device was also taken experimentally, which is  $4.32 \times 10^{15}$  cm<sup>-3</sup>.

## Numerical simulation of the PSCs using SCAPS 1D:

To study a little deeper inside the device physics of our fabricated PSCs, we have studied a numerical simulation of the PSCs using a solar cell capacitance simulator one dimension (SACPS 1D; version 3.3.09) software<sup>5,6</sup>. The three equations that make up this software are Poisson's equation (1), the electron-hole continuity equation (2), and the energy band-to-voltage (J-V) equation (3). These equations are solved to provide the optical and electrical properties.

$$\frac{\partial}{\partial x}(-\varepsilon(x)\frac{\partial V}{\partial x}) = q[p(x)-n(x)+N_D^+(x)-N_A^-(x)+p_t(x)-n_t(x)].$$
(1)

$$\frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial J_p}{\partial x} + G_p - R_p.....3)$$

Where,  $\varepsilon$ , V, q, p(x), n(x),  $N_D^+(x)$ ,  $N_A^-(x)$ ,  $p_t(x)$ , and  $n_t(x)$  denoted the dielectric permittivity, electric potential, electronic charge, free hole concentration, free electron concentration, ionized donor concentration, ionized acceptor concentration, trap density of holes, and trap density of electrons, respectively. The  $J_n$ ,  $J_p$ ,  $R_n$ ,  $R_p$ ,  $G_n$ ,  $G_p$  are referred to the current density, recombination rate, and generation rate corresponding to the electron and hole, respectively.

In this SCAPS 1D numerical simulation, we have presented a list of the main characteristics of materials used in the fabrication of the PSC. The terms thickness, bandgap, electron affinity, relative dielectric permittivity, effective conduction band density, effective valance band density, electron mobility, hole mobility, electron thermal velocity, hole thermal velocity, shallow acceptor density, shallow donor density, total defect density, and absorption coefficient are represented by the terms d,  $E_g$ ,  $\chi$ ,  $\varepsilon_r$ ,  $N_c$ ,  $N_v$ ,  $\mu_n$ ,  $\mu_p$ ,  $V_e$ ,  $V_{h}$ ,  $N_A$ ,  $N_D$ ,  $N_t$ ,  $A_\alpha$  in the Table S12. Except, the thickness of each material, and the absorption coefficient, & the total defect density ( $N_t$ ) of the perovskite

absorber layer, all properties of the materials used in the numerical simulation are taken from previously reported articles.

## References

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